Electronic Patent Application Fee Transmittal								
Application Number:	10798178							
Filing Date:	11-Mar-2004							
Title of Invention:	METHOD OF FORMING POLYSILICON GATE STRUCTURES WITH SPECIFIC EDGE PROFILES FOR OPTIMIZATION OF LDD OFFSET SPACING							
First Named Inventor:	Cheng-Ku Chen							
Filer:	David M. Odell/Denise Wilson							
Attorney Docket Number:	TS03-375							
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Basic Filing:								
Pages:								
Claims:								
Miscellaneous-Filing:								
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Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)	
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